Business

Overview

Si IGBTs and Si diodes are commonly used in high-voltage power electronics wind turbine generators, and industrial robots. TCAD simulation has been us these bipolar devices for over 30 years. Recently, high-precision process sir performance. Accurate process simulation is expected. Furthermore, precialso expected to adapt various carrier lifetime control technologies.

In this project, we established calibrated TCAD setups for Hitachi's side-calibration setups are based on Sentaurus Calibration Workbench, whire users to rapidly calibrate TCAD models. We also included modeling of process. Eventually, we provided well-calibrated process and device reperformance, not only DC characteristics but also switching waveforms.

Modeling and Calibration by Sentaurus Calib

Sentaurus Calibration Workbench is a tool designed to perform sensitivity analysis, search, calibration, and machine learning futool, it interacts with Sentaurus Workbench for setting up and Workbench to speed up simulations by using distributed hete

Figure 1 shows the structure of the side-gate HiGT. In this p calibrations to reproduce the doping profiles of ion implant accurately fitted to SIMS measurement results. We perfor the front side and the modeling of melting laser anneal to

ach as EV, HEV, railway traction, g and performance optimization of ired for these devices to improve their r complex carrier recombination physics is

Jctivity IGBT (side-gate HiGT [1]) and diode. The 2d to increase the value of TCAD by allowing physics for their electron beam irradiation (EBI) ii. The models precisely represent actual device

bench

ons for TCAD simulation tools. It provides evaluation, ugh Sentaurus Calibration Workbench is a standalone ons. It utilizes the job scheduler of Sentaurus uting resources.

Calibration Workbench was used initially for the n. The profiles of boron, phosphorus, and arsenic were ork for the geometric calibration of the gate structure at ackside impurity profiles.

